# **NICK WISWELL**

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#### **PROFILE**

7 years of experience with algorithms and software for real-time process control systems. Experience with collection and analysis of large datasets from industrial systems to improve operational performance. Statistics and optimization background.

#### **EMPLOYMENT**

# **Applied Materials – Algorithm Developer**

2015 - Present

CMP (Chemical-Mechanical Polishing) Process Control Group

- Invented new methods for interpretation of broadband reflectometry spectra and developed software validation for these techniques; new capabilities directly enabled over \$10M in sales
- Created software implementations of these algorithms to achieve real-time process control
- Developed complex simulations to determine optimal configuration of sensors and data collection
- Investigated the feasibility of various new sensors to improve process outcomes, and subsequently led development of a novel acoustic emission control system
- Frequently engaged with analysis of gigabyte or terabyte-scale datasets
- Delivered data visualizations and recommendations to drive organizational decisions
- Contributed to Big Data / AI initiative to facilitate distributed in-fab data warehousing and machine learning to enable real-time inference on spectral data

### **Applied Materials – Process Engineer**

April 2014 - 2015

CMP Disruptive Technology Group

• Developed algorithms for laser positional control to protect critical system components and obtain the optimal dose and distribution in a rotating reference frame

### **PROJECTS**

 Independently designed, deployed, and administered a 300-node bare-metal cluster using IPMI + iPXE for RancherOS diskless boot, Docker Swarm for workload orchestration and custom Python/Bash tooling with Prometheus/Grafana for management

### **PATENTS**

•	Machine Vision as Input to a CMP Process Control Algorithm	#20200094370
•	Polishing System with Capacitive Shear Sensor	#20200070306
•	Training Spectrum Generation for Machine Learning System for Spectrographic Monitoring	#20200005139
•	Polishing Fluid Additive Concentration Measurement Apparatus and Methods Related Thereto	#20190275632
•	Monitoring of Vibrations During Chemical Mechanical Polishing	#20190283204

## **EDUCATION**

# California Polytechnic State University, San Luis Obispo

M.S. Engineering, Concentration in Materials Engineering (2014)

**Master's Thesis:** Design and Fabrication of Electrostatically Actuated Serpentine-Hinged Nickel-Phosphorous Micromirror Devices

**B.S. Materials Engineering,** Minor in Physics (2012)

#### **TOOLS**

Python	C / Cython	Linux	GDB
NumPy	SciPy	Bash	JMP